

## INFORMATION DISCLOSURE CITATION



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Applicant: E. Jennings Taylor

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## U.S. PATENT DOCUMENTS

Examiner	Document No.	Date	Name	Class	Sub	
WL	6,524,461	02/2003	Taylor et al.			
WL	6,303,014	10/2001	Taylor et al.			
WL	5,605,615	02/1997	Goolsby et al.			
WL	5,567,300	10/1996	Datta et al.			
WL	5,476,575	12/1995	Brophy et al.			
WL	5,039,381	08/1991	Mullarkey			

## FOREIGN PATENT DOCUMENT

							Trans	
Examiner	Document No.	Date	Country	Class	Sub	Y	N	

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

WL	West, A.C. et al., "Pulse Reverse Copper Electrodeposition of High Aspect Ratio Trenches and Vias," J. Electrochem. Soc, Vol. 45, No. 9, pp. 3070-3074 (09/1998)
WL	Pletcher, D. et al., Industrial Electrochemistry, Second Edition, Blackie Academic & Professional, London, pp. xi-xvi, 79-81, and 109-133 (1990)
Examiner: William Leader	
Date Considered: 8/20/2004	

\* Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609.

Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.